

Attorney's Docket No.: 042390P3955D

Patent

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In Re Application of:)

Andideh, Ebrahim et al.)

U.S. Serial No: 09/436,092)

Examiner: McDonald, Shantese L.

Filed: November 8, 1999)

Art Unit: 3723

For: POLISH PAD WITH)
NON-UNIFORM GROOVE DEPTH)
TO IMPROVE WAFER POLISH RATE)
UNIFORMITY)

Commissioner for Patents
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FORMAL DRAWINGS SUBMISSION

Enclosed herewith for submission in the United States Patent and Trademark Office
are five (5) sheets of formal drawings for the patent application referenced above.

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Respectfully submitted,

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Dated: March 17, 2005


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